

Acc'nt Nos.	4720-35
Additinal Provisional Serial N.	Filing Date
Agents File Nos.	
Appeal Brief Due	
Appeal Brief Sent	
Applicant	
Application Authorized	
Application Mailed	12/29/2000
Application Requester	
Assignee	UC/IP&C
Attorney	Scott
Attorney Foreign	
Attorney Comments	
BandR No.	DP0301010
Cas Combined with	
Confirmatory License	5/15/2001
Cont. App.	
Countries	
Date Att. Assign.	6/1/2000
Dir citorate Priority	1
Disclosure Submitted	5/7/1999
EI v n Year Amount	
EI ven Yr Fee Due	
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Filing Date	12/29/2000
Final OA Sent	
Final Office Action	10/27/2003
First OA Sent	10/2/2002
First Office Action	7/25/2002
For. Response Due	
Foreign Agents	
Foreign Status	9/14/2001: IPAC notified us not to proceed with the PCT
Foreign Title	
Fourth OA Sent	
Further Office Action	
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IDS Sent	2/21/2001
IL Index Key	10507
IL Number	10507
IL suffix	

IL Type	
Inactivated by DOE	
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International Filing Date	
International Serial No.	
Inventors	Eric C. Honea, Raymond J. Beach
IPAC PCT Req.	
Last Modified Date	11/6/2003
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Notice of Allowance Sent	
Notice of Appeal Due	1/25/2004
Notice of Appeal Sent	
Patent App. Title	Parasitic Oscillation Suppression in Solid State Lasers
Patent Issued Date	
Patent Number	
Patent Status	10/27/2003: Final Office Action--response due 1/27/2004
PCT Due	12/29/2001
PCT I National Entry	
PCT II Demand Due	
PCT II Demand Filed	
PCT II National Entry	
Priority Date	
Provisional Filing Date	
Provisional PCT Due	
Provisional Serial No.	
Publication Cite	
Publication Date	
Related Cases	
Response Due	1/27/2004
Restriction Request	
Restriction Requirement	
Rights Granted Date	5/4/2000
Rights Requested Date	3/15/2000
RL Number	

ROI Title	Optical Coatings for Parasitic Suppression with Near					
S Number	92950					
Second OA Sent	6/20/2003					
Second Office Action	4/15/2003					
Serial Number	09/752848					
Seven Year Amount						
Seven Yr Fee Due						
Seven Yr Fee Paid						
Third OA Sent						
Third Office Action						
Three Year Amount						
Three Yr Fee Due						
Three Yr Fee Paid						
Type Requested	Class Waiver W(C) 92-002					
UC number						
Patent Expiration Date						
Foreign Patent No.						
Foreign Issue Date						
Prov. PCT Due Date						
Non-Lab Employee						
Modification Index	2003310.08431					
No Interest by IPAC						
High 20 Nominated Candidate						
High 20's List	2/24/2000					
Omit	X					
Priority						
Bar Date 1						
Foreign Bar Date						
Bar Date 2						
Bar Date 3						
Bar Date Comments						
Portfolio						
Abstract	4/6/99					
Int'l Search Report						
Written Opinion						
Response Sent						
Small Entity						
Int'l Pr Exam Rpt						
FOA NOA	FOA					
CPA Filed						
First CDA Office Action						

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Second CPA Office Action	[REDACTED]
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Second CPA OA Sent	[REDACTED]
Final CPA OA Sent	[REDACTED]
EUVL	[REDACTED]
EUVL Assignee	[REDACTED]
Search Requested	[REDACTED]
Search Completed	[REDACTED]
Search Sent To	[REDACTED]
For. Misc. Illegible Info	[REDACTED]
Prov PCT Request Sent	[REDACTED]
PCT Request Sent	[REDACTED]
Search Report Resp Sent	[REDACTED]
ISA	[REDACTED]
IPEA	[REDACTED]
Request to Outside Counsel	[REDACTED]
Supp Int'l Search Rpt Rec'd	[REDACTED]
Supp Search Rpt Resp	[REDACTED]
Int'l Pre Exam Resp	[REDACTED]
Written Opinion Resp	[REDACTED]
National Countries	[REDACTED]
National Fees	[REDACTED]
PCT Pub Date	[REDACTED]
PCT Pub Sent Inv.	[REDACTED]
AIPA Applies	AIPA Applies [REDACTED]
New LLNL Inventors	[REDACTED]
Multiple Due Dates	[REDACTED]
Multiple Foreign Due Dates	[REDACTED]
RCE filed	[REDACTED]
First RCE Office Action	[REDACTED]
First RCE Office Sent	[REDACTED]
Second RCE Office Action	[REDACTED]
Second RCE Office Sent	[REDACTED]
Final RCE Office Action	[REDACTED]
Final RCE Office Sent	[REDACTED]
Patent Application	[REDACTED]
U.S. Patent	[REDACTED]